
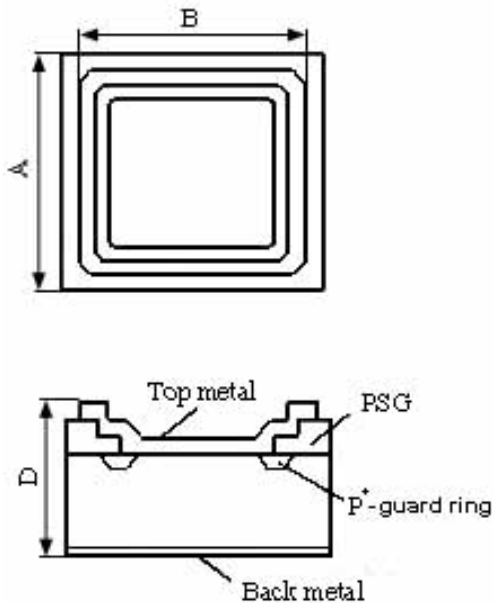


**SCHOTTKY DIODES KDN-10060A.**  
**PRELIMINARY**



Rev.1. Feb. 2010

|  <b>VSP-MIKRON</b>          |               | <b>10A/60V. Die Size-98mil.</b> |                     |                         |
|--|---------------|---------------------------------|---------------------|-------------------------|
| <b>Electrical Characteristics</b>  | <b>Symbol</b> | <b>Unit</b>                     | <b>Spec. limit</b>  | <b>Die Sort</b>         |
| Breakdown Voltage<br>@ $I_R=10mA$  | $V_{BR}$      | V                               | 60                  | 65                      |
| Average Rectified Forward Current  | $I_{F(AV)}$   | A                               | 10,0                | -                       |
| DC Forward Voltage<br>@ $25^{\circ}C, I_F=10,0A$   | $V_F$         | V                               | 0,65                | 0,62                    |
| Maximum Reverse Current<br>@ $25^{\circ}C, V_R=65V$<br>@ $25^{\circ}C, V_R=60V$<br>@ $125^{\circ}C, V_R=60V$ | $I_R$         | mA                              | -<br>0,250<br>140,0 | 0,250<br>0,180<br>130,0 |
| Peak Forward Surge Current 8,3ms<br>single half sine-wave superimposed on<br>rated load (JEDEC METHOD)       | $I_{FSM}$     | A                               | 160                 | -                       |
| Peak Repetitive Reverse Surge Current<br>@ $2,0\mu s, f=1kHz., T_J < 150^{\circ}C.$                          | $I_{RRM}$     | A                               | 3,5                 |                         |
| Electrostatic Discharge Voltage.<br>JEDEC Method. ESD HBM. Contact.  | ESD           | kV                              | $\pm 8$ (contact)   |                         |
| Voltage Rate of Change   | $dV/dt$       | $V/\mu S$                       | 10.000              |                         |
| Operating Junction Temperature   | $T_J$         | $^{\circ}C$                     | 150                 |                         |



| <b>DIM</b>        | <b>ITEM</b>         | <b><math>\mu m</math></b> |
|-------------------|---------------------|---------------------------|
| $A_x$<br>$A_y$    | Wafer Form Die Size | 2500<br>2500              |
| $B_x$<br>$B_y$    | Top Metal Size      | 2360<br>2360              |
| D                 | Thickness           | 350max.                   |
| Scribe line Width |                     | 80                        |

*Top metal:* a) **Al** – for Wire Bonding;  
b) **Al-Ni-Ag** – for Soldering.  
*Backside metal:* **Ti-Ni-Ag**.